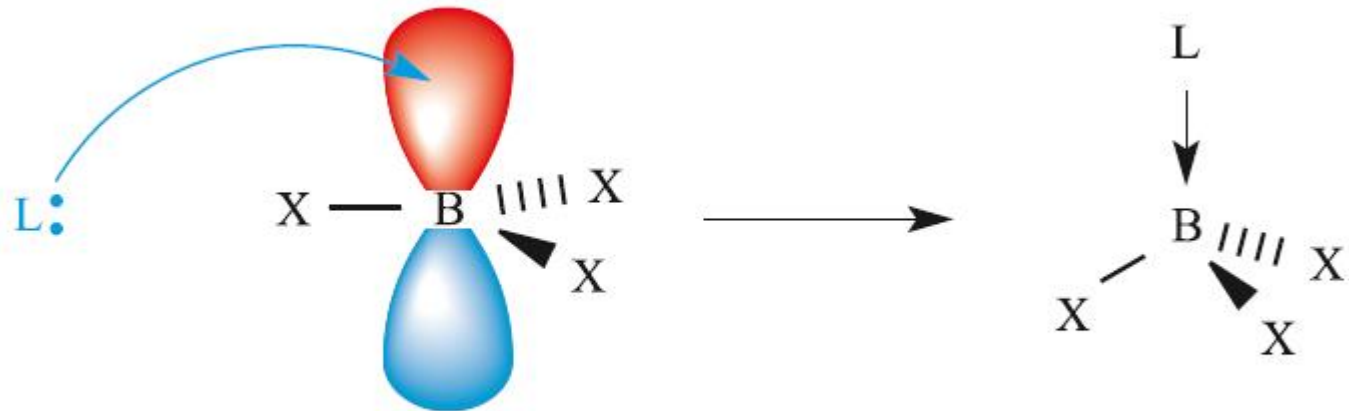


第7回 (1) BX_3 のルイス酸性度

テキスト p.117 (e)-118



hybridized boron centre

hybridized boron centre

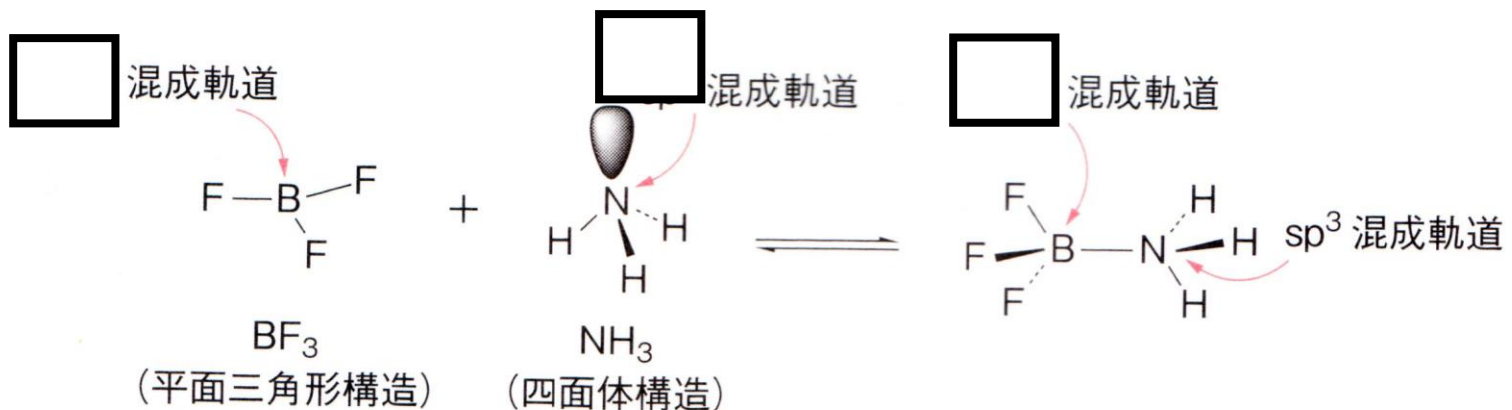
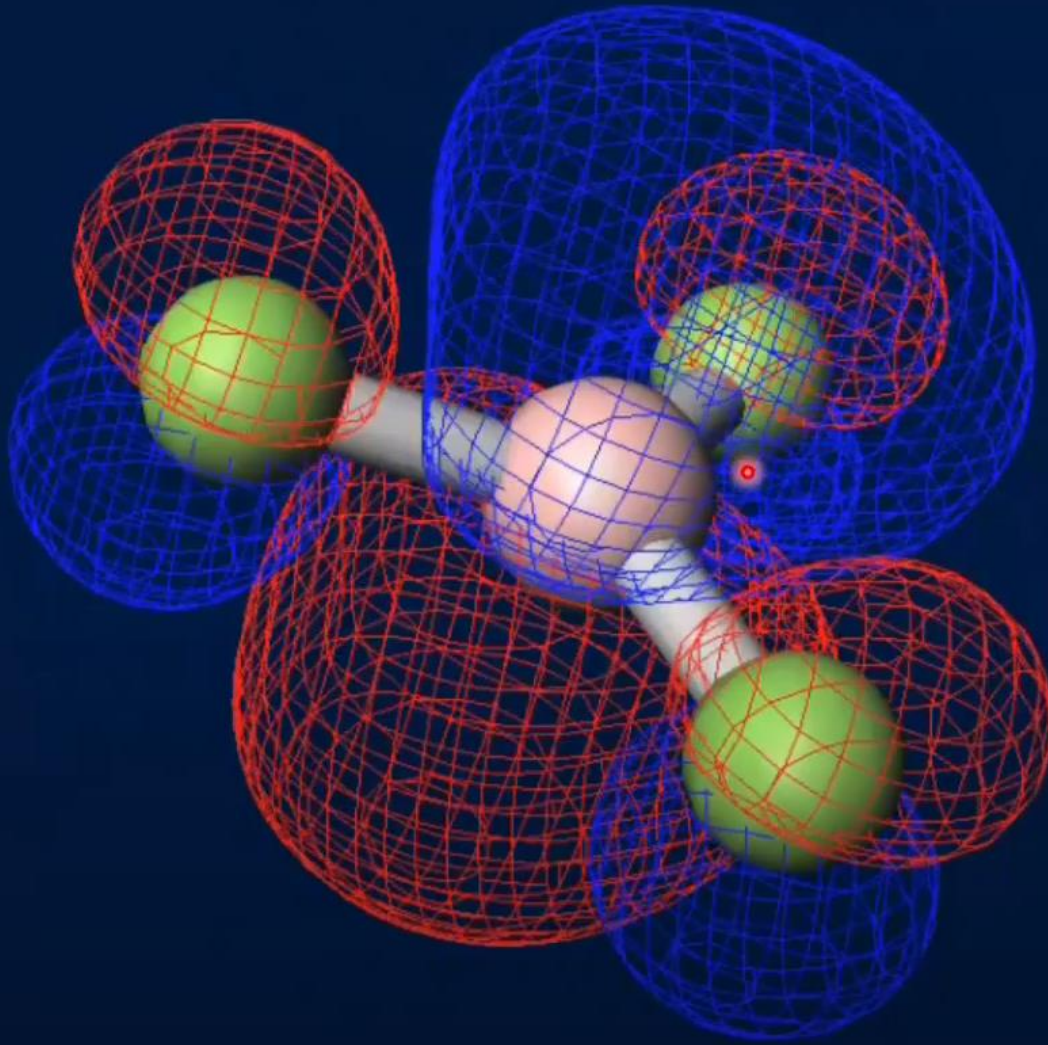


図 5.1 ハロゲン化物とルイス塩基との反応

BF₃の分子軌道(LUMO,
下図の13の軌道)

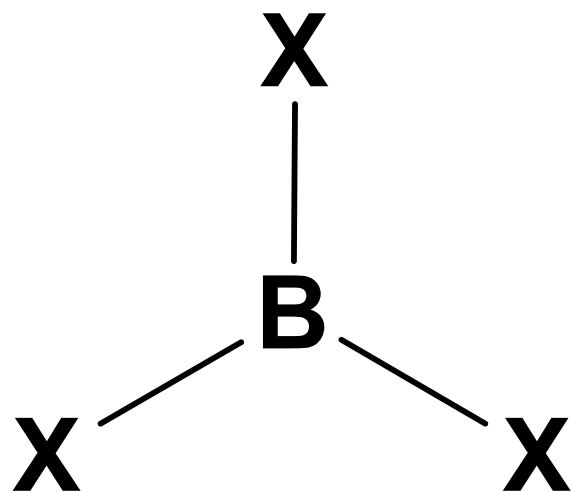


HOMO: 12
HOMO-LUMO Gap :
16.7039 eV
Unit: au. eV

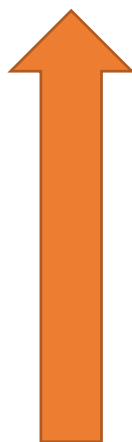
16	6.5434
15	6.5431
14	1.8723
13	1.7643
12	-14.9396
11	-14.9397
10	-15.1505
9	-15.1928
8	-15.1929
7	-18.4593
6	-18.8345
5	-18.8347
4	-22.8042
3	-50.6128
2	-50.6131
1	-51.6471

LUMO: lowest unoccupied molecular orbital (最低空軌道) = 電子を受け取るときに重要になる軌道. (テキストp.93) プリントの最後に若干の説明あり.

BX₃のルイス酸性度



大



電気陰性度

B-X distance

X = F	131 pm
X = Cl	174 pm
X = Br	189 pm
X = I	210 pm

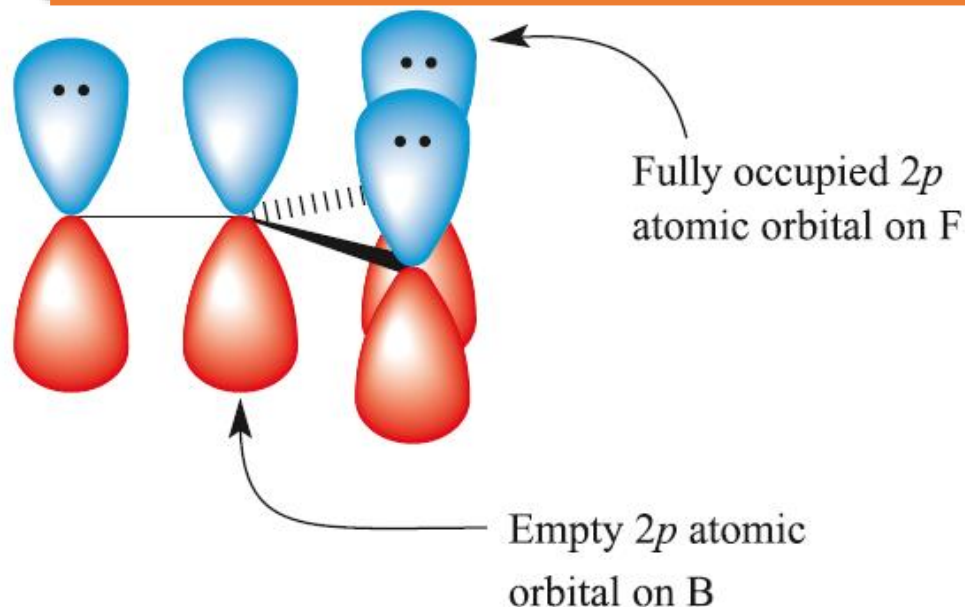
BF₃, BCl₃, BBr₃, BI₃ ← ルイス酸性度の大きさは？

BX₃のルイス酸性度

B-X結合には, 結合性が一部含まれている.
(BI₃を除く)

π結合性の割合: B₃ > B₃ > B₃

Lewis acidity: < <



B-X distance (pm)

*)共有結合半径

X = F 131 pm

71 pm

X = Cl 171 pm

99 pm

X = Br 189 pm

114 pm

X = I 210 pm

133 pm

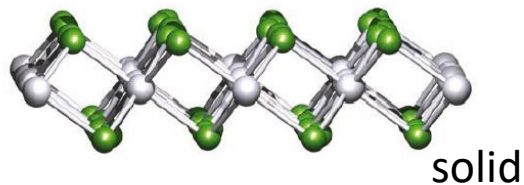
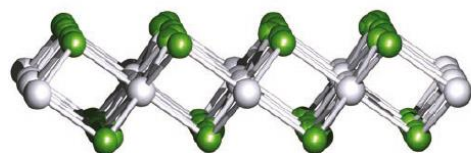
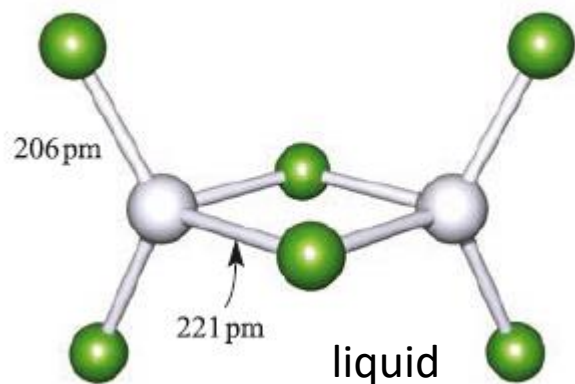
Bの共有結合半径: 82 pm

*)共有結合半径 (テキスト p.27 図2.2)

Friedel-Crafts アルキル化

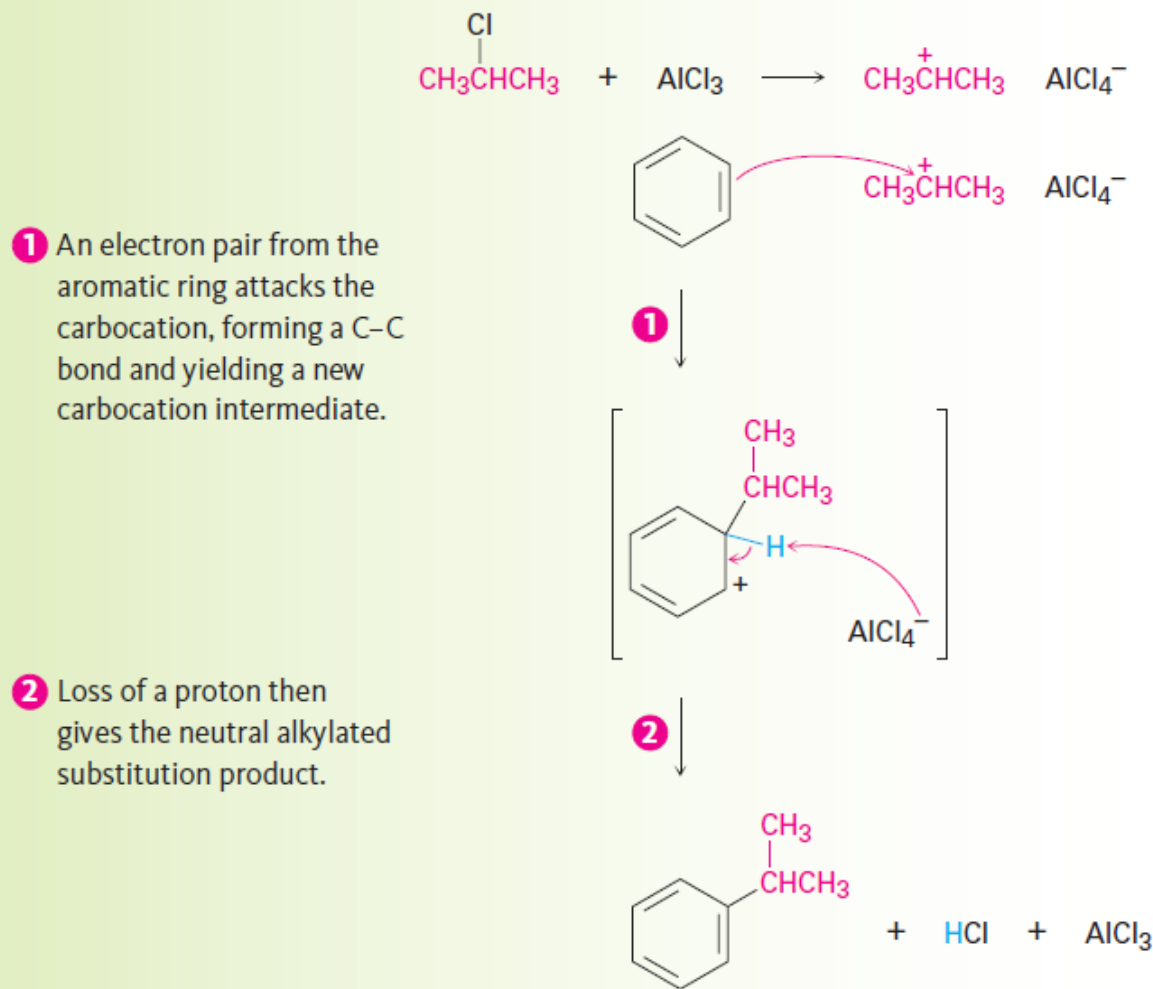


強い Lewis acid



MECHANISM

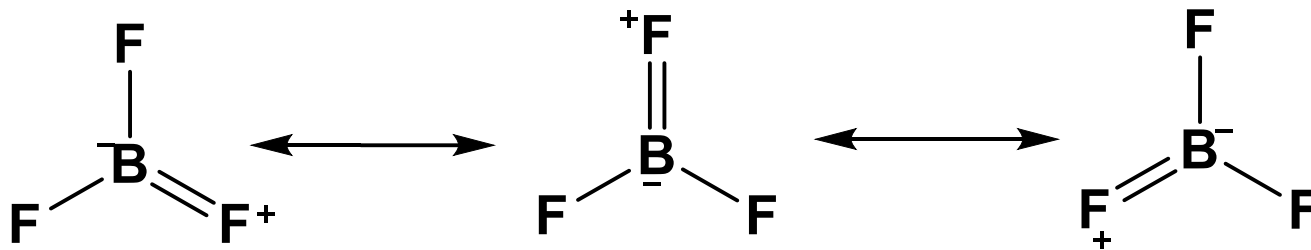
Mechanism for the Friedel-Crafts alkylation reaction of benzene with 2-chloropropane to yield isopropylbenzene (cumene). The electrophile is a carbocation, generated by AlCl₃-assisted dissociation of an alkyl halide.



第7回 (1) BX_3 のルイス酸性度

Lewis acidity: $BF_3 < BCl_3 < BBr_3$

B-X間の π 結合性の割合



$AlCl_3$ 強いLewis acid

Lewis酸触媒 Friedel-Craftsアルキル化
アシル化